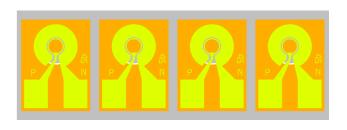


## PRELIMINARY DATASHEET



#### Introduction

This high-performance product is a front side illuminated InGaAs PIN photodiode array chip that features a large  $45\mu$ m detection window, with the 250um die-to-die pitch. This product has low capacitance, high responsivity, low dark current and excellent reliability, designed for long wavelength optical receiver applications with date rate up to 10Gbps at wavelength from 1200nm to 1600nm with single mode fiber. 1x4, 1x8 and 1x12 array are all provided.

## Key Features

# Applications

40G SFP+ LR4

- 45µm optical detection window for better optical alignment
- Front-sided contact pads for flexible wire bonding
- Date rate up to 10Gbps/channel
- Excellent low dark current and capacitance
- -40C to 85C operation range
- Customization for 1x4, 1x8 and 1x12 array configuration
- Highly robust and low-cost 4" IC wafer fab with fast cycle-time
- Deliverable in GCS Known Good Die<sup>™</sup> with 100% testing and inspection
- RoHS compliant

### SPECIFICATIONS (T=25C°)

	Conditions	Min.	Typical	Max.	Unit	Notes
Bandwidth	-5V	8	10	-	GHz	
Wavelength range		910	1310/1550	1650	nm	
Capacitance	-5 V, 1 MHz		0.19	0.22	pF	
Responsivity	@1310 nm	0.85	0.90	-	A/W	
Dark current	-5V	-	1	5	nA	

### ABSOLUTE MAXIMUM RATING

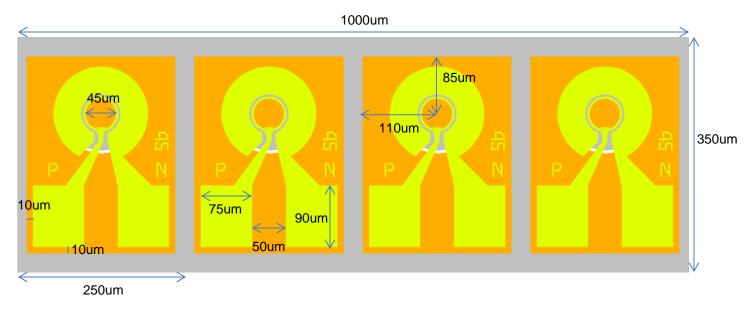
Parameter	Rating			
Operating Temperature	-40C to 85C			
Storage Temperature	-55C to 125C			
Soldering Temperature	260C / 10 sec			

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DIMENSIONS						
	Conditions	Min.	Typical	Max.	Unit	Notes
Detection window			45		μm	
Bonding pad size			75x90		μm²	Ground pads
Metal height of bond pad		1.4	1.6	-	μm	Au metal
Die height		110	120	130	μm	
Die width		340	350	360	μm	
Die length			1		mm	For 1x4 Array
			2		mm	For 1x8 Array
			3		mm	For 1x12 Array
Die pitch			250		Um	



P/N: DO297\_45um\_E1\_1x4

Attention: InP brittle material and electrostatic sensitive device. Observe precaution for handling.

## About GCS:

GCS has a long history manufacturing and shipping both GaAs and InGaAs based photo diodes since 2000. Our state of art manufacturing facility is located in Torrance, California, and has about 10,000 square feet of fab space with a capability of about 1200 4-inch wafers per month and expandable to 2000 wafers per month. GCS as a world-class semiconductor device manufacturer has been delivering a total of over 30 million photo diodes with various date rates and applications used for optical communications, which have been deployed in field by top tier optical transceiver companies worldwide.

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